

Ref #	Hits	Search Query	DBs	Default Operator	Plurals	Time Stamp
L1	45207	((cvd (chemical same vapor same deposit\$3) ALD (atomic same layer same deposit\$3) pulse plasma)).CLM.	US-PGPU B	OR	ON	2005/07/08 12:44
L2	620	((substrate wafer) and (reactor chamber) and (vapor and (reactant precursor))).CLM.	US-PGPU B	OR	ON	2005/07/08 12:37
L3	42697	(pulse cycle).CLM.	US-PGPU B	OR	ON	2005/07/08 12:38
L4	27146	(PSG (phosphosilicate and glass) (phosphorous and dop\$3 (("Si" "O.sub.2")))) (silicon same (oxide dioxide))).CLM.	US-PGPU B	OR	ON	2005/07/08 12:41
L5	42	1 and 2 and 3 and 4	US-PGPU B	OR	ON	2005/07/08 12:42
L6	45287	((cvd chemisorb\$3 (chemical same vapor same deposit\$3) ALD (atomic same layer same deposit\$3) pulse plasma)).CLM.	US-PGPU B	OR	ON	2005/07/08 12:45
L7	42	6 and 2 and 3 and 4	US-PGPU B	OR	ON	2005/07/08 12:45

Ref #	Hits	Search Query	DBs	Default Operator	Plurals	Time Stamp
L2	2113	(438/758,788,787,788,792).CCLS.	US-PGPU B; USPAT; USOCR; EPO; JPO; DERWENT ; IBM_TDB	OR	OFF	2005/07/08 11:52
L3	1658	2 and (plasma cvd pulse)	US-PGPU B; USPAT; USOCR	OR	ON	2005/07/08 12:08
L4	36	3 and (phosphorus near5 dop\$3 near5 (silicon near3 (oxide dioxide)))	US-PGPU B; USPAT; USOCR	OR	ON	2005/07/08 11:55
L5	180	3 and (PSG (phosphorus near5 dop\$3 near5 (silicon near3 (oxide dioxide))))	US-PGPU B; USPAT; USOCR	OR	ON	2005/07/08 12:12
L6	180	3 and (PSG (phosphorus near5 dop\$3 near5 ("Si" adj3 "O.sub.2")silicon near3 (oxide dioxide))))	US-PGPU B; USPAT; USOCR	OR	ON	2005/07/08 12:10
L7	0	2 and (plasma cvd pulse)	EPO; JPO; DERWENT ; IBM_TDB	OR	ON	2005/07/08 12:01
L8	1836	(427/489,792,497,509,529, 544,563,568,570,574,578, 582,583,588).CCLS.	US-PGPU B; USPAT; USOCR	OR	OFF	2005/07/08 12:08
L9	1490	8 and (plasma cvd pulse ALD (atomic near5 layer near5 deposit\$3)(chemical near5 vapor near5 deposit\$3))	US-PGPU B; USPAT; USOCR	OR	ON	2005/07/08 12:09
L10	61	9 and (PSG (phosphorus near5 dop\$3 near5 ("Si" adj3 "O.sub.2")silicon near3 (oxide dioxide))))	US-PGPU B; USPAT; USOCR	OR	ON	2005/07/08 12:10
L11	197	3 and (PSG (phosphosilicate near5 glass) (phosphorus near5 dop\$3 near5 (silicon near3 (oxide dioxide))))	US-PGPU B; USPAT; USOCR	OR	ON	2005/07/08 12:13
L12	70	9 and (PSG (phosphosilicate near5 glass) (phosphorus near5 dop\$3 near5 (silicon near3 (oxide dioxide))))	US-PGPU B; USPAT; USOCR	OR	ON	2005/07/08 12:13
L13	248	11 12	US-PGPU B; USPAT; USOCR	OR	ON	2005/07/08 12:13